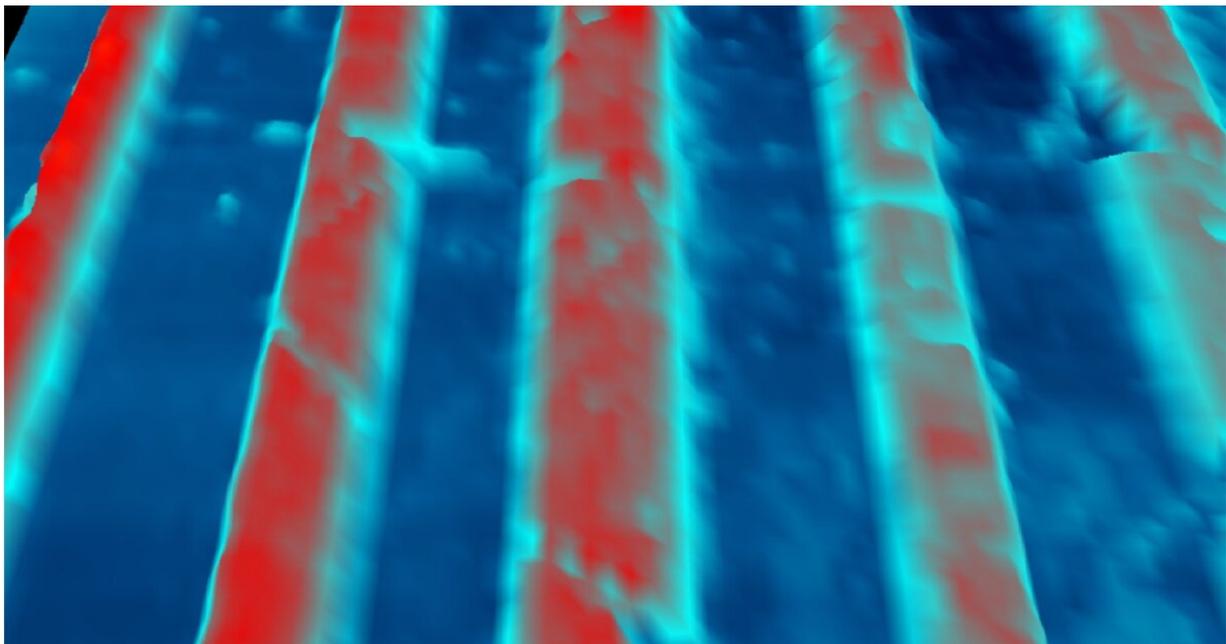


New technique could lead to rewritable memory devices and low-power electronics

October 1 2020, by Theresa Duque



Near-field scanning microscope image of nanocircuits "written" into a 2-D device made of boron nitride and graphene. Credit: Alex Zettl/Berkeley Lab

A research team led by Alex Zettl, senior faculty scientist in Berkeley Lab's Materials Sciences Division and professor of physics at UC Berkeley, has developed a new technique for fabricating tiny circuits from ultrathin materials for next-generation electronics, such as rewritable, low-power memory circuits. Their findings were reported in the journal *Nature Electronics*.

Using the nanofabrication facility at the Molecular Foundry, the researchers prepared two different 2-D devices known as van der Waals heterostructures: one by sandwiching graphene between two layers of boron nitride; and another by sandwiching [molybdenum disulfide](#).

When applying a fine electron beam to the boron-nitride "sandwiches," the researchers demonstrated that they can "write" nanoscale conducting channels, or nanocircuits, into the core "active" layer by controlling the intensity of electron beam exposure while properly controlling a back-gate electric field.

When written into the graphene or molybdenum disulfide layer, these nanocircuits allow high densities of electrons, or quasiparticles called holes, to accumulate and move through the semiconductor along narrow predetermined tracks at ultrahigh speeds with few collisions—like cars racing through a freeway within inches of each other without crashing or stalling.

The researchers also found that reapplying the electron [beam](#) with a special back-gate to the 2-D materials can erase nanocircuits that have already been written—or write additional or different circuits in the same device, which suggests that the technique has great potential for next-generation reconfigurable 2-D electronics.

Importantly, the researchers demonstrated that the material's conducting states and ultrahigh electronic mobility persists even after the [electron beam](#) and the back-gate have been removed. This finding is critical to many applications, including energy-efficient nonvolatile memory devices that do not require constant power to retain data, said lead author Wu Shi, a project scientist in Berkeley Lab's Materials Sciences Division and the Zettl Lab at UC Berkeley.

More information: Wu Shi et al. Reversible writing of high-mobility

and high-carrier-density doping patterns in two-dimensional van der Waals heterostructures, *Nature Electronics* (2020). [DOI: 10.1038/s41928-019-0351-x](https://doi.org/10.1038/s41928-019-0351-x)

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